

organo-silicon compounds

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$\{B[C_2H_4Si(CH_3)NH]_2 [C_2H_4Si(CH_3)N(SiH_2Ph)] \}_n$: The First Polyborosilazane Precursor for Silicoboron Carbonitride Stable to 2200 °C — [synthesis and pyrolytic conversion]. — (WANG, ZHI-CHANG; GERSTEL, PETER; KAISER, GERHARD; KUMMER, HORST; BILL, JOACHIM; ALDINGER, FRITZ; RIEDEL, RALF; Chem. Lett. (2001) 4, 296-297; Dep. Chem., Northeast. Univ., Shenyang 110006, Peop. Rep. China; EN)